

# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/749,171	12/27/2000	Cleopatra Cabuz	1100.1116101	4937
128	7590 01/16/2002			
HONEYWELL INTERNATIONAL INC. 101 COLUMBIA ROAD P O BOX 2245			EXAMINER:	
			SIMKOVIC, VIKTOR	
MORRISTOWN, NJ 07962-2245				
	,		ART UNIT	PAPER NUMBER
			2812	
			DATE MAILED: 01/16/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

*		Application No.	Applicant(s)			
		09/749,171				
Office Action Summary		Examiner	CABUZ ET AL.			
		Viktor Simkovic	Art Unit			
	The MAILING DATE of this communication app					
Period for Reply						
I HE I - Exter after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. In period for reply specified above is less than thirty (30) days, a reply operiod for reply is specified above, the maximum statutory period we are to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ti within the statutory minimum of thirty (30) da iill apply and will expire SIX (6) MONTHS from cause the application to become ARADONIA	mely filed  ys will be considered timely.  n the mailing date of this communication.			
1)🛛	Responsive to communication(s) filed on 27 E	Pecember 2000 .				
2a) 🗌		s action is non-final.				
3)	_					
Disposition of Claims						
4)⊠ Claim(s) <u>1-19</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
	Claim(s) <u>7-13</u> is/are allowed.					
6)⊠						
7)🖂	7) Claim(s) 19 is/are objected to.					
8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9)☐ The specification is objected to by the Examiner.						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)∐ T	he proposed drawing correction filed on					
	If approved, corrected drawings are required in repl		·			
12)☐ The oath or declaration is objected to by the Examiner.						
Priority ur	nder 35 U.S.C. §§ 119 and 120					
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority documents have been received.						
2	2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.  14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. \$ 110(a) (to a provisional application).						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).  a) The translation of the foreign language provisional application has been received.						
15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
ttachment(s						
)  Notice (	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) tion Disclosure Statement(s) (PTO-1449) Paper No(s) <u>2.3</u> .	5) Notice of Informal P	(PTO-413) Paper No(s) atent Application (PTO-152)			
Patent and Trad O-326 (Rev.			Part of Paper No. 4			

Application/Control Number: 09/749,171

Art Unit: 2812

### **DETAILED ACTION**

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in-

(1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or

(2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).

Claims 1-2, 4-6, 14-18 are rejected under 35 U.S.C. 102(e) as being anticipated by Atobe et al. Atobe et al. teach a method for making a thin silicon structure comprising the steps of:

providing a glass substrate (Fig. 5A);

providing a silicon substrate having two planar surfaces (Fig. 4A);

forming a recess in said glass substrate (Fig. 5C);

bonding said silicon substrate to said glass substrate such that at least part of said silicon wafer bonds the glass wafer and part of it overhangs the recess (Fig. 4I);

selectively removing a portion of said silicon substrate to form an overhanging structure (Fig. 4I).

Please note that layer 112 is just a doped portion of the silicon layer and thus is still the silicon substrate surface.

Application/Control Number: 09/749,171

Art Unit: 2812

With regard to claim 2, see Fig. 5F, item 236, which is an electrode film formed on the glass substrate. With regard to claim 4, see column 16, line 20, where a gold electrode is taught. With regard to claim 5, see column 16, line 38, where anodic bonding is taught. With regard to claim 6, see column 14, line 27, where RIE is taught. With regard to claim 14-18, claim 14 only differs from claim 1 in that it does not specify the types of wafers, and claims 15-18 simply specify this, namely specifying glass and silicon wafers.

### Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over Atobe et al. While Atobe et al. does not specifically mention a Ti-Pt electrode, such electrode are well known in the art and it would have been obvious to one of ordinary skill in the art at the time of the invention to use such an electrode, since this is common in the art.

Official notice is taken.

Application/Control Number: 09/749,171

Art Unit: 2812

# Allowable Subject Matter

Claims 7-13 are allowed.

Claim 19 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: Prior art of record fails to teach the method of forming a thin structure such that a glass wafer with a recess is bonded to a silicon wafer with a metal layer corresponding to the recess, and the silicon layer is etched to form an overhanging structure over the recess, using the metal layer as an etch stop, after which the metal layer is removed.

#### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Applicant's attention is especially drawn to U.S. Pat. No. 6,242,276 and Japanese Patent JP410242483A.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Viktor Simkovic whose telephone number is 703-308-6170. The examiner can normally be reached on Mon - Fri, 9:00 - 6:00, except every other Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 703-308-3325. The fax phone numbers

Page 5

for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-1782.

Viktor Simkovic January 10, 2002

Supervice of the Committee of 1887